

[FTu3A.5] Revealing conditions required for achieving Kerr bistable memory based on whispering gallery mode cavity

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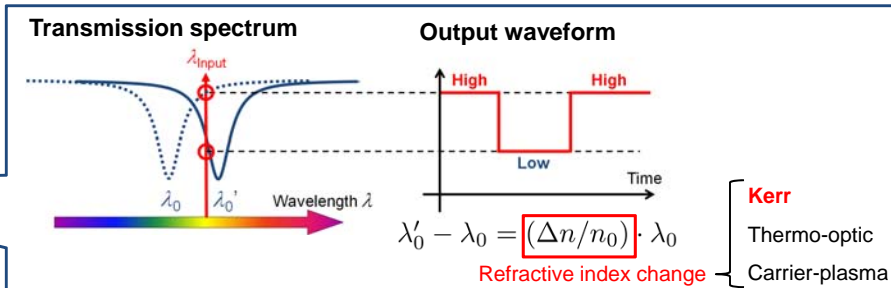
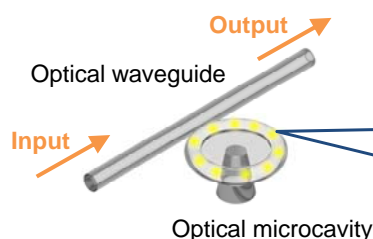
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Abstract

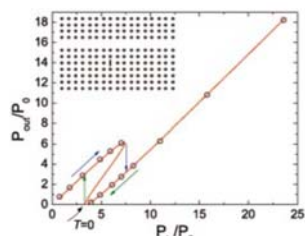
We numerically studied conditions required for achieving a memory operation based on Kerr bistability in the presence of the thermo-optic effect by assuming a silicon nitride microring cavity and a silica toroid microcavity. We revealed the effect of the absorption on the performance to Kerr bistable memory and show the trade-off between switching speed and required power.

Background: Kerr bistability in a microcavity

Optical bistability in a microcavity



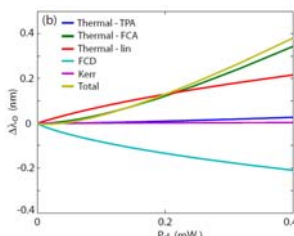
Kerr bistable memory



M. Fatih *et al.*, Appl. Phys. Lett. **83**, 2739 (2003).

Kerr bistable memory in an ideal material

Refractive index change in a Si



P. Barclay, *et al.*, Opt. Express **13**, 801- (2005).

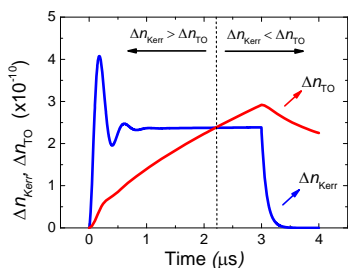
Kerr can be easily overwhelmed by other effects

Objective

- Study the required detuning & coupling between the cavity and the waveguide to achieve Kerr bistable memory in the presence of TO effect.
- Demonstrate the trade-offs between switching speed and required power.

Strategy

Kerr effect vs TO effect

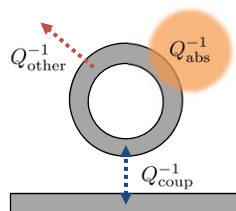


Fast switching speed (i.e. low- Q_{load}) is necessary for avoiding influence from TO effect.

$$\text{Speed} \propto Q_{load}^{-1}$$

W. Yoshiki and T. Tanabe, J. Opt. Soc. Amer. B **29**, 3335-3343 (2012).

Quality factor



Loaded quality factor

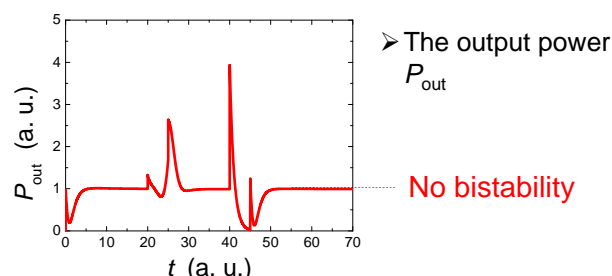
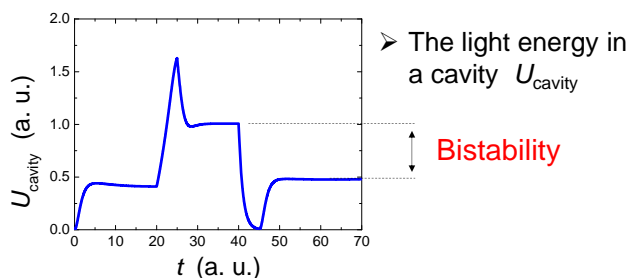
$$Q_{load} = \omega_0 \tau_{load} = \omega_0 (\tau_{abs}^{-1} + \tau_{other}^{-1} + \tau_{coup}^{-1})^{-1}$$

τ_{abs}^{-1} : Absorption loss (material)

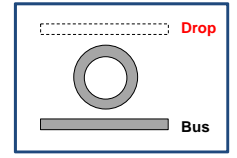
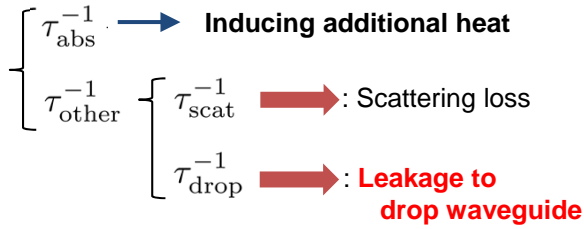
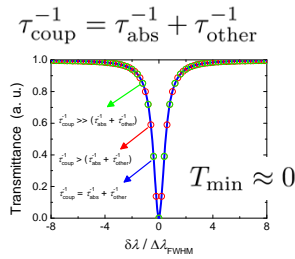
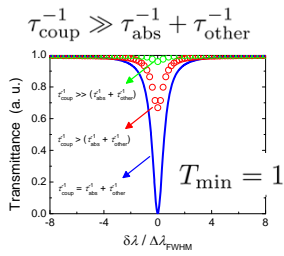
τ_{other}^{-1} : Other intrinsic loss (structure)

τ_{coup}^{-1} : Leakage to waveguide (position of waveguide)

An example of Kerr memory operation

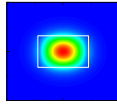


Transmittance



Calculation model

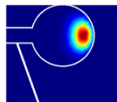
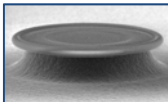
Platforms



Si₃N₄ ring

Bandgap : 250 nm
 $Q_{abs} : 5.3 \times 10^6$

A. Gondarenko et al., Opt. Express 17, 11366- (2009)

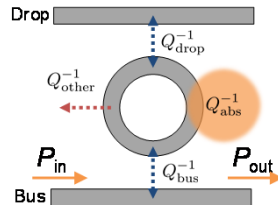


Silica toroid

Bandgap : 140 nm
 $Q_{abs} : 2 \times 10^{11}$ ($Q_{water} \cong 10^8$)

H. Rokhsari et al., Appl. Phys. Lett. 85, 3029- (2004)
 A. Savchenkov et al., Phys. Rev. A 70, 051804 (2004)

Coupled mode theory (CMT)



- Cavity mode: $\frac{da}{dt} = \left(j\omega'_0 - \frac{1}{2\tau_{load}} \right) a + \sqrt{\frac{1}{\tau_{bus}}} \exp(j\theta) s_{in}$
- Input mode: $s_{out} = s_{in} - \sqrt{\frac{1}{\tau_{bus}}} \exp(-j\theta) a$
- Resonant frequency: $\omega'_0 = \frac{n_0}{n_0 + \Delta n_{Kerr} + \Delta n_{TO}} \omega_0$
- Refractive index change: $\Delta n_{Kerr} = \frac{2n_0^2 c}{n_0 V} U_{cavity}$
 $\Delta n_{TO} = n_0 \xi T$

W. Yoshiki and T. Tanabe, J. Opt. Soc. Amer. B 29, 3335-3343 (2012).

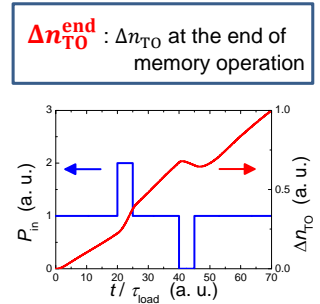
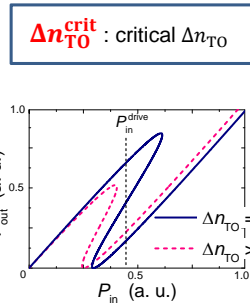
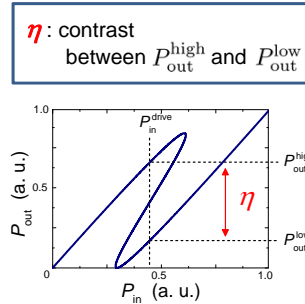
Required condition

$$\eta = (P_{out}^{high} - P_{out}^{low}) / P_{out}^{high} \gg 0$$

: Contrast at output.

$$\sigma = \Delta n_{TO}^{end} / \Delta n_{TO}^{crit} < 1$$

: Induced heat during memory operation

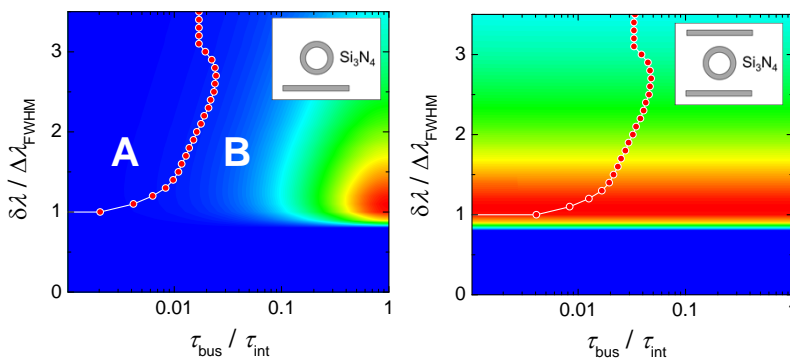


Results

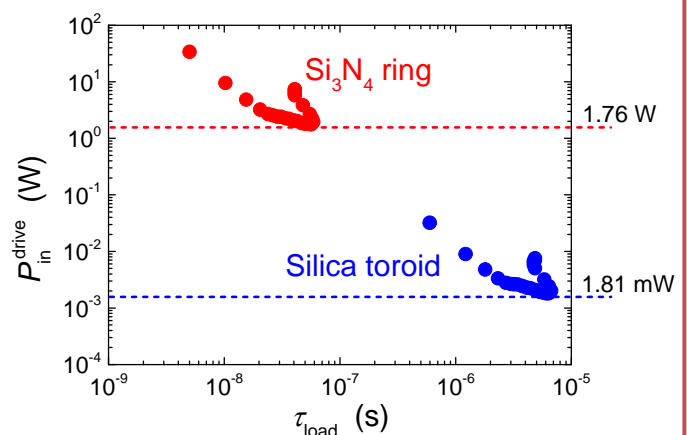
Required value of τ_{bus} and detuning $\delta\lambda$

0 1 η : Output contrast obtained by static analysis
 A: Usable area ($\sigma < 1$)
 B: Unusable area ($\sigma > 1$)

Obtained by transient analysis



Trade-off between τ_{load} and P_{drive}



- Trade-off between τ_{load} and P_{drive}
- P_{drive} cannot be reduced when Q_{abs} is large.

Conclusion

We revealed τ_{bus} and $\delta\lambda$ values required for achieving a Kerr bistable memory in the presence of TO effect. In addition, we demonstrated impact of Q_{abs} on required power and switching speed.

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